

# MSE-619 Nanofabrication with focused electron and ion beams

Hoffmann Patrik Willi, Utke Ivo

Cursus	Sem.	Туре	Language of	English
Advanced Manufacturing		Obl.	teaching	English
Materials Science and Engineering		Obl.	Credits Session	2
			Exam	Multiple
			Workload	60h
			Hours	28
			Courses	12
			Exercises	8
			TP	8
			Number of positions	20

#### Frequency

Every 2 years

#### Remark

Next time August 2017

## Summary

Nanofabrication with focused charged particle beams (SEM, FIB) and their applications such as lithography, gas assisted deposition / etching, and milling are discussed and the limitations of these processes are developed based on the acquired understanding of the interactions.

## Content

- Introduction to Scanning Electron / Ion Microscopes: SEM, Ga-FIB, He-FIB, AuSi-FIB
- Electron / Ion interaction with solids: concepts and simulations
- Analysis with focused electron and ion beams: EDX, EBIC, EBSD, tomography
- Nanofabrication with FIB and FEB: milling, deposition, etching, lithography

• Novel Add-Ons for Nanomanipulation and Nanoanalysis inside electron microscopes: 4-point electrical measurements, positioning systems for nanostructures, magnetic bead detection, mechanical measurements: tensile, bending, and compressive loading of nanostructures, 3D topography with in-situ atomic force microscopy, chemical depth profiling by combined FIB-mass spectroscopy. Live demonstrations: Add-ons, SEM, Dual Beam.

## Note

Limited to 16 students

## **Keywords**

FIB, FEB, nanofabrication, integrated setups for in-situ measurements (chemical, mechanical, structural, electronical) of nanostructures and their in-situ synthesis (gas injection)

## **Learning Prerequisites**

## **Recommended courses**

Physics and Chemistry at university level, general concepts of NanoSciences and Fabrication